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## Y<sub>2</sub>(Ge,Si)O<sub>5</sub>:Pr phosphors: multimodal temperature and pressure sensors shaped by bandgap management†

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Luminescence thermometers and manometers are among the most paramount emerging applications of phosphors nowadays, and remote reading is not the only attractive advantage they offer. Presently, truly encouraging examples offering both a wide operating range and appreciating thermal sensitivity are still limited. Double-mode sensors are especially attractive but pose additional problems to design them and control their properties. In this paper, we investigate Y<sub>2</sub>(Ge<sub>x</sub>Si<sub>1-x</sub>)O<sub>5</sub>:0.05 mol%Pr powder phosphors methodically varying the Ge:Si molar ratio to design their properties both in optical thermometry and manometry. We show that activation energy for thermal quenching of the 5d → 4f luminescence may be tuned and the mechanism of this process controlled. Consequently, fine-tuning of the luminescent properties important in thermometry may be managed. Specific properties of the 5d → 4f luminescence allow dual-mode thermometry to be executed using either luminescence intensity ratio or the emission decay kinetics for that purpose. The highest values of the thermometric relative sensitivity depend on the Ge:Si molar ratio and range from ~2.5 to 3.5% K<sup>-1</sup>. The temperature range of the best performance may also be effectively tuned by adjusting the Ge:Si molar ratio. Controlling the Ge:Si proportion also allows the sensitivity of these phosphors in manometry to be improved. The Y<sub>2</sub>(Ge<sub>0.10</sub>Si<sub>0.90</sub>)O<sub>5</sub>:0.05%Pr material presents the second-best ever reported sensitivity of 1.28 nm GPa<sup>-1</sup>. Consequently, the Y<sub>2</sub>(Ge<sub>x</sub>Si<sub>1-x</sub>)O<sub>5</sub>:0.05%Pr phosphors are useful for both temperature and pressure monitoring, and their performance in both functionalities may be effectively tuned by means of the Ge:Si molar ratio. Our findings may serve as a guide for researchers searching for novel optical thermometers and manometers.

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## 1. Introduction

Apart from such applications as modern lighting solutions,<sup>1,2</sup> persistent phosphors<sup>3,4</sup> or scintillators,<sup>5,6</sup> photocatalysis<sup>7</sup> and others, luminescence thermometry and manometry belong to

the most intensely developing research areas of luminescent materials.<sup>8–11</sup> Both these physical quantities greatly affect chemical, physical, geological, and biological processes. Thus, their monitoring is crucial in research and technology. Luminescence thermometry presents great potential in *in vitro* and *in vivo* bio- and medical imaging and treatment but also appears attractive in such fields as micro- and nano-electronics, aviation industry, space research, measurements of temperature distribution over (large) surfaces.<sup>12–15</sup> Emerging applications involve *e.g.* catalysis or the protection of structural materials.<sup>16,17</sup> The reader may find more comprehensive information on these topics in numerous reviews or books published in recent years.<sup>10,14,18–23</sup> Measuring very high pressure is necessary for many technological and scientific processes, among them in such sophisticated circumstances as simulating the conditions of stars and planet formation or geological processes.<sup>24</sup>

The common requirement of all considered applications of luminescent thermometers and manometers is their high

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† Electronic supplementary information (ESI) available: VRBE diagrams of the Y<sub>2</sub>(Ge<sub>x</sub>Si<sub>1-x</sub>)O<sub>5</sub> host lattices, structural X-ray diffraction measurements, energy level diagram of Pr<sup>3+</sup>, decay traces of the 5d → 4f and 4f → 4f emissions, configuration coordinate diagram for Pr<sup>3+</sup> ions, time-resolved spectroscopic measurements, schematic presentation of energies for luminescence intensity integrations (A1, A2, and A3), thermal evolution of the integrated areas of the three emissions with temperature, calibration curves for the LIR<sub>1</sub>, LIR<sub>2</sub>, and LIR<sub>3</sub>, repeatability measurements, temperature uncertainty for LIR<sub>1–3</sub> and based on 5d → 4f decay traces. See DOI: 10.1039/d1tc03202j



thermal sensitivity, low inaccuracy of temperature/pressure readouts, good repeatability, as well as chemical and physical stability when used. In luminescence thermometry, the required temperature operating range is entirely defined by the application considered. In bio- or medical uses, only a narrow range of physiological temperatures is of interest. On the other hand, catalysis, aerospace, or surface temperature distribution may easily require measuring temperature over wide ranges, at least several hundred degrees, and often even above 1000 °C. For luminescent thermometers, it is a great challenge and it is known that only a few phosphors are able to satisfy such requirements.<sup>25,26</sup> On the other hand, the search for phosphors that can serve as luminescent thermometers with such rigorous requirements is a fantastic challenge.

We have recently shown that bandgap engineering in  $\text{Pr}^{3+}$ -activated phosphors offers the possibility to accurately control important thermometric parameters – mainly (relative) thermal sensitivity, temperature uncertainty, and the operating range of luminescent thermometers.<sup>27–30</sup> Upon UV  $4f \rightarrow 5d$  excitation, a number of  $\text{Pr}^{3+}$ -activated materials exhibit three emissions showing different dependence on temperature: (i)  $5d \rightarrow 4f$  broad-band luminescence in the UV part of the spectrum, (ii) narrow-line luminescence due to the  $^3\text{P}_0 \rightarrow ^3\text{H}_j$  transition which appears mainly around 500 nm ( $^3\text{P}_0 \rightarrow ^3\text{H}_4$ ), and (iii) narrow-line  $^1\text{D}_2 \rightarrow ^3\text{H}_j$  emission in the red part of the spectrum, which partly overlaps with the  $^3\text{P}_0 \rightarrow ^3\text{H}_6/^3\text{F}_2$  luminescence. We have previously shown that the luminescence intensity ratio may be used to measure temperature with very high relative sensitivity.<sup>27–29</sup> On the other hand, the ratio of the (ii) and (iii) transition intensities may be useful to extend the operating range of luminescence thermometers using  $\text{Pr}^{3+}$  emissions.

Furthermore, we have shown that also decay time of the  $\text{Pr}^{3+}$   $5d \rightarrow 4f$  emission offers the possibility of temperature measuring in the range of several hundred degrees.<sup>29</sup> This finding proved that the  $\text{Pr}^{3+}$ -activated luminescent thermometers may be used as dual-mode temperature sensors. This enhances the versatility of such sensors.

In the present paper, we examine the performance of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  family of luminescent thermometers varying the Si:Ge ratio. We also discuss in depth the important changes of spectroscopic properties resulting from this change. Fig. 1 presents a vacuum referred binding energy (VRBE) diagram together with  $\text{Pr}^{3+}$  levels for the investigated phosphors.

The reader may find such VRBE diagrams with the levels of all  $\text{Ln}^{3+}$  and  $\text{Ln}^{2+}$  ions for these hosts in Fig. S1a–f (ESI†). Analogously, the required parameters to construct such a diagram are in Table S1 (ESI†). This may be useful for many researchers. As the Ge content increases in the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  phosphors, the bandgap of the host decreases. This strongly affects the properties of the  $5d \rightarrow 4f$  luminescence, especially its thermal quenching. This, in turn, affects strongly the temperature dependence of the intensity ratio of the above-mentioned luminescence features of the dopant. It also appeared interesting to test the effect of pressure on the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  phosphor luminescent properties. To the

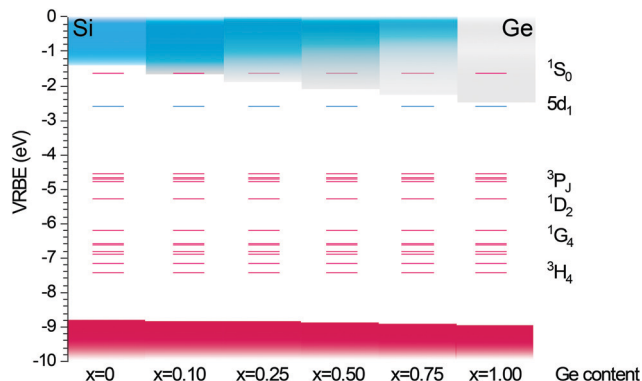


Fig. 1 The effect of the Ge:Si ratio on the bandgap structure of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5$  host lattices and the relative position of the electronic levels of  $\text{Pr}^{3+}$ .

best of our knowledge, the effect of pressure on the  $5d \rightarrow 4f$  luminescence of  $\text{Pr}^{3+}$  was previously investigated only in  $\text{Y}_3\text{Al}_5\text{O}_{12}:\text{Pr}$ .<sup>31</sup> One can, however, find a number of Pr-activated luminescent materials in which the impact of pressure on the intra-configurational  $4f \rightarrow 4f$  transitions was tested.<sup>32–35</sup> However, as we already mentioned above, in contrast to the very sensitive  $5d \rightarrow 4f$  transition, the  $4f \rightarrow 4f$  transitions are by their very nature not strongly affected by the external compression.

## 2. Experimental

$\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  luminescent powders were prepared *via*  $\text{Li}_2\text{SO}_4$  flux-aided synthesis.<sup>29</sup> To prevent any cross-relaxation processes between the  $\text{Pr}^{3+}$  ions the low concentration of the dopant, 0.05 mol% with respect to  $\text{Y}^{3+}$ , was chosen. Ge was assumed to replace Si forming  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  solid solutions where  $x = 0, 0.1, 0.25, 0.5, 0.75, 1$  (0%, 10%, 25%, 50%, 75%, 100%).  $\text{Y}_2\text{O}_3$  (Stanford Materials, 99.999%),  $\text{SiO}_2$  (Umicore, 99.99%),  $\text{GeO}_2$  (Alfa Aesar, 99.999%), and  $\text{Pr}_6\text{O}_{11}$  (Stanford Materials, 99.99%) were used as the starting reagents. They were thoroughly ground in an agate mortar and mixed with  $\text{Li}_2\text{SO}_4$  (Alfa Aesar, 99.9%) flux. Then the mixture was placed in a platinum crucible and transferred to a chamber furnace. The samples were heated at 1300 °C for 5 hours. The heating rate was 5 °C per min up to 800 °C and 3 °C per min above this temperature. After cooling, the powders were recovered by washing out the flux a few times with hot deionized water. Afterward, the white phosphor powders were dried at 80 °C for 10 h at a reduced pressure of a vacuum laboratory dryer.

### Measurements

**X-ray diffractometry.** The X-ray diffraction (XRD) patterns of all the synthesized powders were measured with a D8 Advance diffractometer (Bruker) equipped with a  $\text{Cu K}\alpha_1$  ( $\lambda = 1.5406$  Å) tube. The measurements were performed in the  $2\theta = 10^\circ$ – $65^\circ$  range with the  $2\theta = 0.008^\circ$  step and the counting time was 0.2 s.

**Fourier-transform infrared spectroscopy.** Fourier-transform infrared spectra (FTIR) were recorded on a Bruker Vertex



70 FTIR spectrometer. FTIR spectra were recorded in the transmission mode in the range 4000–400  $\text{cm}^{-1}$  with the 1  $\text{cm}^{-1}$  resolution. The powders were dispersed in dry KBr and then palletized employing uniaxial pressing. For these measurements, the FTIR sample chamber was flushed continuously with  $\text{N}_2$  prior to the data acquisition.

**Photoluminescence measurements.** Photoluminescence (PL), excitation spectra (PLE), and decay kinetics (DEC) in the temperature range 15–675 K were recorded using an FLS1000 spectrometer from Edinburgh Instruments Ltd. For temperature measurements, a helium closed-cycle cryostat from Lake Shore Cryotronics, Inc. was used. Samples were mounted on its copper cold-finger using Silver Adhesive 503 from Electron Microscopy Sciences. The excitation radiation source for PL and PLE spectra was an ozone-free xenon lamp (450 W). Emission decay curves were measured upon excitation with a xenon flash lamp ( $\mu\text{F2}$ ) of a microsecond pulse duration for the 4f–4f emissions or a 250 nm picosecond pulsed emitting diode, EPLED-250, for the 5d–4f luminescence. The spectrofluorometer was equipped with double-grating excitation and emission monochromators with a focal length of 32.5 cm, and the emitted light was recorded by a Hamamatsu R928P photomultiplier. PL spectra were corrected for the luminescence channel spectral efficiency and PLE spectra were corrected for the incident radiation intensity. The decay curves of the luminescence excited by pulsed picosecond diodes were recorded with the low-noise F-G05 detector featuring a Hamamatsu H5773-04 photomultiplier. The decay curves were fitted using Fluoracule Software employing single- or double-exponential equation, whichever was needed. Deconvolution of the excitation pulse was employed. The software uses the Levenberg–Marquardt algorithm to calculate the decay time(s) and the corresponding errors of the fitting parameters.

**Calculation of thermometric parameters.** For details of the calculations of thermal sensing parameters please refer to the provided ESI† file. Additional information is published elsewhere.<sup>9,20,21</sup>

**Diamond-anvil cell loading procedure and pressure measurements of PL and PLE spectra.** High-pressure measurements were carried out in a Merrill–Bassett diamond-anvil cell (DAC), with 500  $\mu\text{m}$  cuvette size, where the anvils are directly mounted on steel supporting plates, and the pressure is adjusted by the use of three metal screws. Stainless steel sheets (250  $\mu\text{m}$  thick) were used as gaskets. The gaskets were pre-indented down to  $\sim 80$   $\mu\text{m}$  thick, and then drilled with an electro-driller, in order to make a hole with  $\sim 200$   $\mu\text{m}$  diameter (pressure chamber aperture). After mounting the metal gasket on a diamond, a small sphere of ruby and the sample were placed in the gasket hole and filled with methanol:ethanol:water (16:3:1) pressure transmitting medium (hydrostatic up to  $\sim 10$  GPa). The high-pressure values were determined using ruby  $R_1$  fluorescence line shift, excited with a 532 nm laser, and using a ruby calibration curve available elsewhere.<sup>36</sup> For technical reasons, *i.e.*, naturally low PL signal intensity from the tiny amount of the compressed material loaded into the DAC (sample size  $\approx 200$   $\mu\text{m}$ ), large slits had to be used. This necessarily

resulted in significantly broader bands, compared to the PL temperature measurements.

### 3. Results

#### 3.1. Structural properties of $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5\text{:Pr}$ materials

The oxyorthosilicates crystallize in two types of monoclinic structures, X1 and X2. The large rare earth (RE) ions (with the ionic radius  $> 0.92$  Å, *e.g.*  $\text{La}_2\text{SiO}_5$ ,  $\text{Tb}_2\text{SiO}_5$ ) form a monoclinic X1 type of structure in the space group  $P2_1/c$  (#14), whereas smaller ions give the X2 type of structure with the space group  $C2/c$  (#15).<sup>37</sup> Yet, in the case of  $\text{Y}_2\text{SiO}_5$  (YSO) the type of structure is strongly dependent on the fabrication temperature. Below 1190 °C it can form an X1 type of structure, and at higher temperatures of synthesis – X2.<sup>38</sup> On the other hand, it was found that isostructural oxyorthogermanate crystallizes only in the monoclinic X2 type of structure in the space group of  $C2/c$  (#15), regardless of the preparation temperature.<sup>39</sup> The present research was conducted on phosphors showing the X2 structure. Table S2 (ESI†) presents the crystallographic data for the  $\text{Y}_2\text{SiO}_5$  and  $\text{Y}_2\text{GeO}_5$  host lattices.

In the monoclinic  $C2/c$   $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5\text{:Pr}$ , there exist two crystallographically different  $\text{Y}^{3+}$  sites, Y1 and Y2, showing different coordination numbers, CN = 7 and 6, respectively (see Fig. S2a and b, ESI†). As the ionic radius of  $\text{Pr}^{3+}$  is  $\sim 8.5\%$  larger compared to  $\text{Y}^{3+}$  it is expected and spectroscopically confirmed that  $\text{Pr}^{3+}$  (as well as  $\text{Ce}^{3+}$ ) occupy mainly the Y1 site whose coordination number and the RE–O distances are larger compared to Y2.<sup>38,40,41</sup> At low concentrations, the occupancy of the Y2 is negligible.

The phase purity of the examined solid solutions with different Ge content was verified by means of powder XRD and the results are presented in Fig. S3 (ESI†). The simulated patterns of  $\text{X2-Y}_2\text{SiO}_5$  (ICSD#291362) and  $\text{Y}_2\text{GeO}_5$  (ICSD#260425) are given as well. Crystallographically, all the synthesized compounds are high-quality products. Only in the case of  $\text{Y}_2\text{GeO}_5$ , was a minimal amount of  $\text{GeO}_2$  found giving a diffraction line at  $28.6^\circ$  (ICSD #59639). Along with the incorporation of Ge into the host lattice, one can observe a shift of diffraction lines towards lower angles. This was expected, since the  $\text{Ge}^{4+}$  ionic radius is larger than  $\text{Si}^{4+}$ , and the interplanar distances in the unit cell increase accordingly.<sup>42</sup> Additionally, in the case of the (Ge, Si) solid solutions, broadening of the diffraction lines can be observed. This is a direct consequence of distortion in the local structure of the solid solutions and disturbance of the otherwise flat lattice planes. This proves that the (Ge, Si) mixed phosphors are indeed solid solutions. The previously published EDS analysis of Ge and Si confirmed that the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5\text{:Pr}$  phosphor compositions agree with the nominal formulas.<sup>43</sup>

The FTIR spectra of the investigated samples are presented in Fig. 2. In the Ge-free  $\text{Y}_2\text{SiO}_5\text{:Pr}$  sample, the spectrum shows only the bands of typical rare earth oxyorthosilicates.<sup>44</sup> The bands between 1150–850  $\text{cm}^{-1}$  are attributed to the asymmetric and symmetric stretching vibrational modes within the  $\text{SiO}_4$



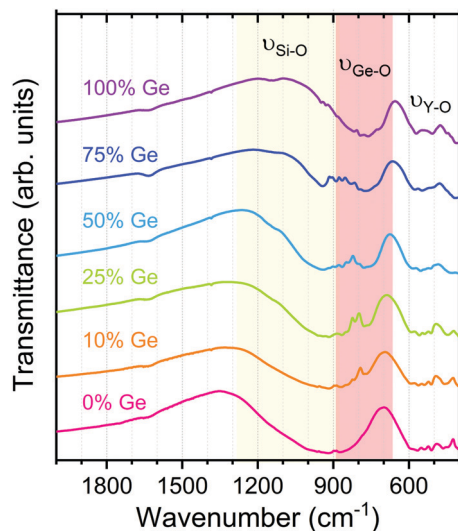


Fig. 2 FTIR spectra of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  materials.

tetrahedra. The bands around  $450\text{ cm}^{-1}$  are assigned to the bending vibrations of the O–Si–O bonds.<sup>45</sup> They overlap with vibrations of the  $\text{YO}_x$  ( $x = 6, 7$ ) polyhedra ( $600\text{--}400\text{ cm}^{-1}$ ). With the increase of germanium content, a new structured absorption band appears with a maximum of around  $770\text{ cm}^{-1}$ . As expected, its intensity grows together with the Ge incorporation into the host lattice. These features are assigned to the stretching symmetric and asymmetric vibrations in the  $\text{GeO}_4$  unit.<sup>29,46</sup> With the varying Ge:Si ratio, some small changes in the positions of the various features of the IR spectra can be noted, which reflect small changes in the bond lengths.<sup>44</sup> The IR spectroscopic data show that the replacement of (a fraction of) Si with Ge (to engineer the host bandgap), also affects the phonon energies of the host lattice. These have important consequences on the material's photoluminescence properties affecting the nonradiative processes experienced by the excited electron.<sup>47</sup> Consequently, thermometric parameters are also expected to be influenced through such effects.

### 3.2. Luminescence properties

Fig. 3 presents the PLE spectra of the  $611\text{ nm Pr}^{3+}$  luminescence (from the  $^1\text{D}_2$  level) in the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5$  phosphors, taken at  $11\text{ K}$ .

The broadband located in the UV part is assigned to the inter-configurational  $^3\text{H}_4 \rightarrow 5\text{d}$  ( $4\text{f} \rightarrow 5\text{d}$ ) transition of  $\text{Pr}^{3+}$ . Its peak locates around  $248\text{--}250\text{ nm}$ , and it is hardly affected by the Ge:Si ratio. The narrow lines in the blue and orange part of visible radiation are attributed to the intra-configurational  $4\text{f} \rightarrow 4\text{f}$  transitions. Due to the low  $C_1$  symmetry of the dopant, the number of observed lines is large.<sup>47–49</sup> It is striking that the relative intensity of the  $4\text{f} \rightarrow 4\text{f}$  transitions compared to the  $4\text{f} \rightarrow 5\text{d}$  one decreases strongly when the Ge content increases. Qualitatively, this is expected taking into account the data presented in Fig. 4. Namely, increasing the Si concentration leads to intense  $5\text{d} \rightarrow 4\text{f}$  emission, and then not much energy is left for the  $4\text{f} \rightarrow 4\text{f}$  luminescence. Consequently, when the

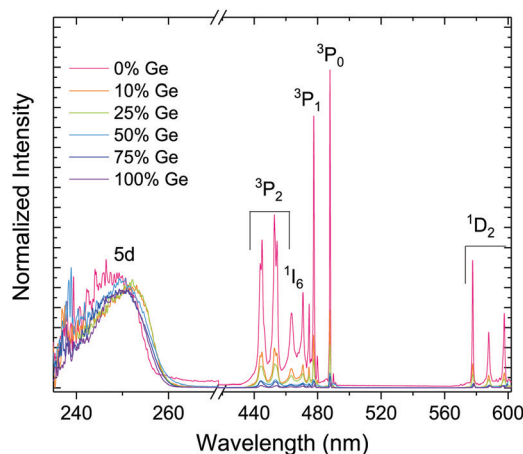


Fig. 3 Excitation spectra of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:0.05\%\text{Pr}$  phosphors taken at  $11\text{ K}$  monitoring the red luminescence from the  $^1\text{D}_2$  level ( $\sim 611\text{ nm}$ ).

less-energetic radiation excites electrons through the  $4\text{f} \rightarrow 4\text{f}$  transitions, relatively high-intensity luminescence is generated. In the PLE spectra this gives the observed effect. Fig. 4 presents the PL spectra of all the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:0.05\%\text{Pr}$  investigated phosphors, recorded in the  $11\text{--}700\text{ K}$  temperature range, under excitation at the respective maxima of the  $4\text{f} \rightarrow 5\text{d}$  excitation bands (Fig. 3). The broadband located in the UV part of the spectra results from the  $4\text{f}^15\text{d}^1 \rightarrow ^3\text{H}_{4-6}, ^3\text{F}_{2-4}$  transition of  $\text{Pr}^{3+}$ . A series of narrow lines is seen in the visible part of the spectra. They correspond to the  $^3\text{P}_0 \rightarrow ^3\text{H}_{4,5,6}, ^3\text{F}_{2,3,4}$  (spreading from bluish-green to red) and  $^1\text{D}_2 \rightarrow ^3\text{H}_{4,5}$  (red) intra-configurational transitions. The latter partially overlap with a fraction of the luminescence from the  $^3\text{P}_0$  level which will be discussed later. The corresponding diagram of the energy levels of  $\text{Pr}^{3+}$  with the assignment of the various transitions is presented in Fig. S4a and b (ESI†).

The emission spectra of the investigated materials present significant changes when the temperature increases from  $11$  to  $700\text{ K}$  (Fig. 4a–f). The variations are also dependent on the Ge content in the host. In the Ge-free  $\text{Y}_2\text{SiO}_5:\text{Pr}$ , the parity-allowed  $5\text{d} \rightarrow 4\text{f}$  transition intensity decreases as the temperature increases until  $500\text{ K}$ . At this point this luminescence gets completely quenched. Simultaneously, the intensities of the intra-configurational  $4\text{f} \rightarrow 4\text{f}$  features increase at the expense of the inter-configurational one. This effect is primarily seen in the case of luminescence from the  $^1\text{D}_2$  level compared to the  $5\text{d} \rightarrow 4\text{f}$  emission. Hence, when the luminescence from the  $5\text{d}$  level gets thermally quenched, at least a fraction of the energy migrates to the lower-lying  $^3\text{P}_0$  and (more effectively) to the  $^1\text{D}_2$  level. The results are in good agreement with the previously published data for the  $\text{YSO}:\text{Pr}$  single crystal,<sup>50,51</sup> which is indirect proof that the powder phosphors are of good quality.

As the Ge content increases, the  $5\text{d} \rightarrow 4\text{f}$  luminescence becomes more susceptible to temperature quenching. In the material with  $50\%$  of Si replaced with Ge it lasts till  $\sim 300\text{ K}$ , whereas in the Si-free  $\text{Y}_2\text{GeO}_5:\text{Pr}$  there is no trace of this luminescence, even at the lowest temperature ( $11\text{ K}$ ) we could achieve. This is the expected effect of the bandgap engineering.





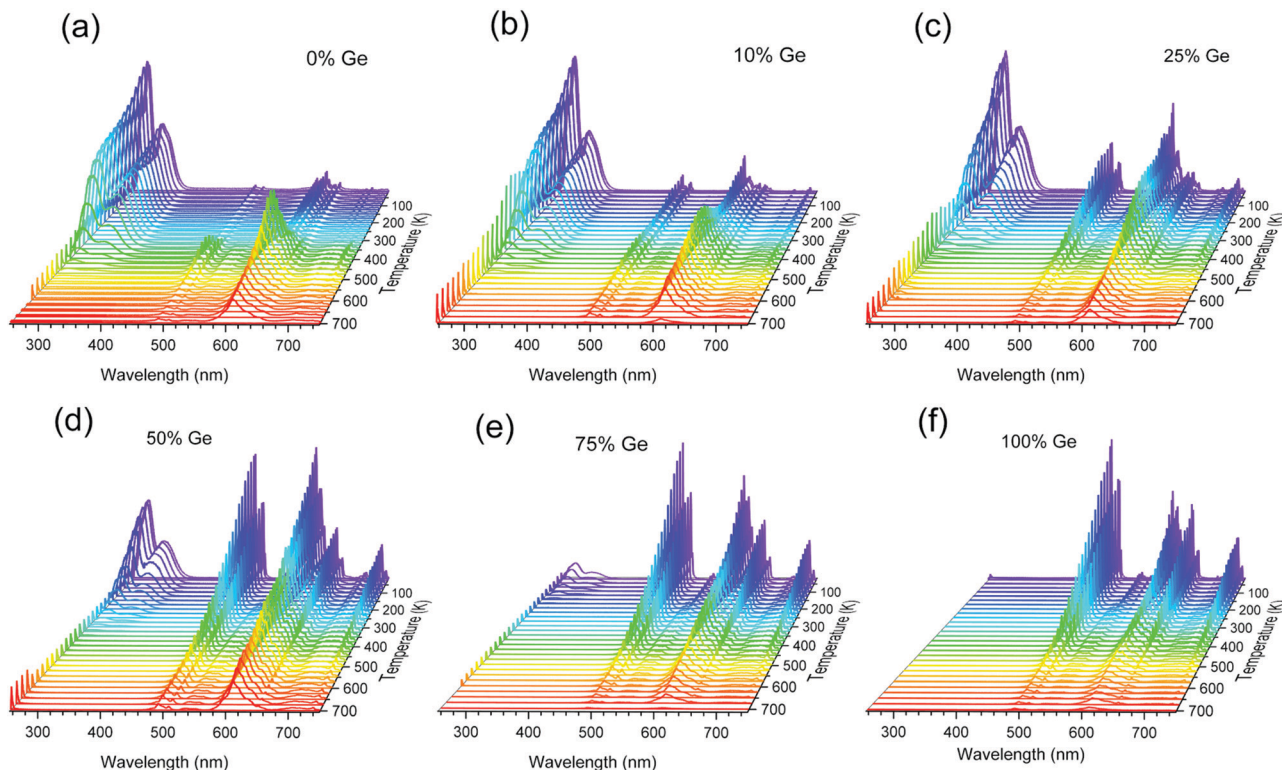


Fig. 4 Temperature-dependent photoluminescence spectra of the  $\text{Y}_2\text{Ge}_x\text{Si}_{1-x}\text{O}_5:0.05\%\text{Pr}$  phosphors, in the  $T$ -range of 11–700 K. (a)  $x = 0$ , (b)  $x = 0.10$ , (c)  $x = 0.25$ , (d)  $x = 0.50$ , (e)  $x = 0.75$ , and (f)  $x = 1.0$ .

Replacing Si by Ge has to reduce the forbidden energy gap of the host lattice. This is mostly caused by the lowering of the CB, which decreases the distance between the band and the (potentially) emitting  $5d_1$  level. When the CB and  $5d_1$  overlap no luminescence from the latter can be produced. It is noteworthy that for higher Ge contents (25–75%), quenching of the  $5d \rightarrow 4f$  luminescence hardly exerts any effect on the  $4f \rightarrow 4f$  transition intensities.

This indicates that in the Ge-rich phosphors, the energy from the  $5d_1$  is mostly converted into heat, instead of being used to produce luminescence. The fraction of electrons from the  $5d_1$  level, which does not produce the  $5d \rightarrow 4f$  emission, relaxes nonradiatively by-passing the lower-lying  $^3\text{P}_0$  and  $^1\text{D}_2$  levels.

Fig. S5a–e (ESI†) presents the temperature-dependence of the decay traces of the  $\text{Pr}^{3+} 5d_1 \rightarrow 4f$  luminescence in the

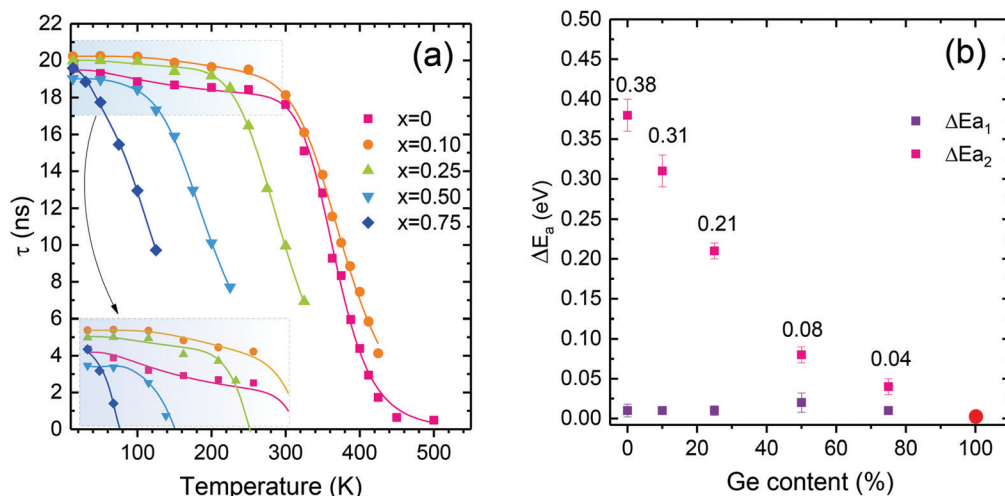


Fig. 5 (a) Temperature dependence of the  $5d \rightarrow 4f$  PL decay time of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  phosphors, under 250 nm excitation. The inset is a magnification of the low-temperature range of the curves to better reveal the complex shape of the curves in the low range of temperature. (b) Dependence of the activation energies,  $\Delta E_{a1}$  and  $\Delta E_{a2}$ , of the  $5d \rightarrow 4f$  emission thermal quenching, derived using eqn (1).



investigated compositions. All decay traces can be fitted using a single-exponential function. Fig. 5a presents the dependence of the derived decay times on temperature for the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5\text{:Pr}$  phosphors. In each case, the low-temperature (11 K) lifetime is very similar and reaches  $\tau \sim 20$  ns. This meets the literature data for  $\text{Y}_2\text{SiO}_5\text{:Pr}$  single crystals.<sup>50,52</sup> With increasing temperature, the  $5d_1 \rightarrow 4f$  luminescence decay time shortens, yet in each composition at a different temperature range. The quenching temperature ( $T_{50\%}$ ) (defined as the temperature at which the luminescence decay time is two-fold shorter than at the lowest temperature<sup>53</sup>) in  $\text{Y}_2\text{SiO}_5\text{:Pr}$  occurs at 360 K, whereas in  $\text{Y}_2(\text{Ge}_{0.75}\text{Si}_{0.25})\text{O}_5\text{:Pr}$  at 125 K. These data reflect the changes observed in the emission spectra (see Fig. 4), and they were already discussed above. Thus, with the increasing Ge content, a decreasing energy barrier for the  $5d_1 \rightarrow 4f$  luminescence thermal quenching is proved. This is exactly what we expected from the bandgap engineering and is discussed in the Introduction section.

To further investigate and better understand the temperature quenching of the  $5d \rightarrow 4f$  luminescence and find the values of energy barrier(s) for the process, we fitted the data presented in Fig. 5a with eqn (1):<sup>29,54</sup>

$$\rho = \frac{1}{\tau} = \frac{1}{\tau_0} + \sum_{i=1}^2 B_i \times \exp\left(-\frac{\Delta E_{ai}}{k_B T}\right), \quad (1)$$

where  $\rho$  and  $\tau$  are the luminescence transitions probability rate ( $\rho_{\text{NR}} + \rho_{\text{R}}$ ) and the decay time at given  $T$  ( $1/(\rho_{\text{NR}} + \rho_{\text{R}})$ ), respectively.  $\tau_0$  represents the radiative lifetime ( $1/\rho_{\text{R}}$ ) in the (assumed) absence of luminescence quenching/non-radiative relaxation at the lowest temperatures.  $B$  is a parameter that corresponds to the inverse of the nonradiative decay time at  $T \rightarrow 0\text{K}$ ,  $\Delta E_{ai}$  is the activation energy and  $k_B$  is the Boltzmann constant ( $8.6177 \times 10^{-5} \text{ eV K}^{-1}$ ). Here, we applied the equation with two ( $I = 2$ ) barrier processes. This choice was made since we regularly observed a slight decrease of the lifetime at low temperature values (see the inset in Fig. 5a) and a drastic quenching at higher temperature values. Similar behavior is often observed and reported in the literature, but the authors usually use the classic single-barrier approach neglecting the small shortening of the lifetime.<sup>55</sup> The corresponding values of activation energies derived using eqn (1) are presented in Fig. 5b. Here,  $\Delta E_{a1}$  represents the low-efficiency quenching process, whose nature remains unclear, at present. It is responsible for the small shortening of the  $5d \rightarrow 4f$  luminescence decay time, seen in the inset of Fig. 5a. Its value is very similar for all compositions, which has to reflect a similar origin of the effect in all these materials. On the other hand,  $\Delta E_{a2}$  decreases with the increase of Ge content, as was expected and explained in the Introduction. For the  $\text{Y}_2\text{SiO}_5\text{:Pr}$  material, the activation energy is  $0.38 \pm 0.02 \text{ eV}$ . This value matches well the one reported by Pejchal *et al.* for  $\text{Y}_2\text{SiO}_5\text{:Pr}$  single crystal.<sup>50</sup> With the increase of the Ge content, the  $\Delta E_{a2}$  activation energy continuously decreases, reaching  $0.04 \text{ eV}$  in the  $\text{Y}_2(\text{Ge}_{0.75}\text{Si}_{0.25})\text{O}_5\text{:Pr}$  sample. In the  $\text{Y}_2\text{GeO}_5\text{:Pr}$  material, this luminescence is not seen down to 11 K, see Fig. 4f.

The  $\Delta E_{a2}$  values represent the energy barrier of the main process responsible for the thermal quenching of the  $5d \rightarrow 4f$  luminescence. In general, this may occur as a result of thermally induced photoionization, which transfers the excited electron from the  $5d$  level to the host conduction band. Direct evidence for such a mechanism could be provided by measurements of photoconductivity of the materials, which we are not able to perform at present (and they are hardly possible to perform with powders, in fact). However, van Der Kolk showed experimentally that in  $\text{Y}_2\text{SiO}_5\text{:Pr}$  single crystals this photoionization is inefficient.<sup>56</sup> This infers that the thermal quenching of the  $5d \rightarrow 4f$  emission occurs through a cross-over mechanism, in which the thermal energy is used by the excited electron to overcome the energetic barrier generated by the crossing parabolas of the  $5d$  and  $4f$  levels of  $\text{Pr}^{3+}$ . Fig. S6 (ESI<sup>†</sup>) presents schematically the difference between both mechanisms of thermal quenching of the intra-configurational luminescence. The thermally activated cross-over process is often observed in  $\text{Pr}^{3+}$  compounds.<sup>55,57,58</sup> This requires that the energetic separation of the  $4f^1 5d^1$  and the next-lower-lying level of the  $4f^2$  configurations is not significant, and the former is well below the host conduction band.<sup>47</sup>

The concluded cross-over mechanism of the  $5d \rightarrow 4f$  luminescence quenching in  $\text{Y}_2\text{SiO}_5\text{:Pr}$  is consistent with the temperature-induced changes in the PL spectra of Ge-free  $\text{Y}_2\text{SiO}_5\text{:Pr}$  phosphor and the one containing 10% Ge (see Fig. 4a and b). With temperature elevation, the  $4f \rightarrow 4f$  luminescence intensity in these two phosphors increases at the expense of the decreasing  $5d \rightarrow 4f$  luminescence. Yet, when the Ge content is higher than 10%, the intensities of the  $4f \rightarrow 4f$  transitions hardly change, and the  $5d \rightarrow 4f$  luminescence weakens. This indicates that for the Ge-rich samples the photoionization mechanism dominates when the  $5d \rightarrow 4f$  luminescence undergoes quenching. Recently, Ueda *et al.*<sup>55</sup> reported similar results for the  $\text{Y}_3\text{Al}_{5-x}\text{Ga}_x\text{O}_{12}\text{:Pr}$  garnet materials. They also concluded that replacing Al by Ga changes the mechanism of the  $5d \rightarrow 4f$  luminescence thermal quenching from a thermally activated cross-over process into the thermally activated photoionization mechanism.

While thermally activated photoionization is a fairly widely accepted luminescence quenching mechanism,<sup>54,55,59,60</sup> it may not be entirely intuitively obvious, at first. Namely, one might suppose that an electron thermally raised to the conduction band should be capable of returning to the level it has just escaped and possibly produce a photon of light. In fact, in scintillation, an electron which happened to get to the conduction band after absorption of gamma-particles indeed falls onto the activator excited level to produce a photon of light, afterwards. However, this happens when the conduction band and the excited (emitting) level below it are not thermally coupled. If they are, scintillation becomes ineffective—the electron is not able to localize on the excited/emitting level for a time long enough to relax radiatively from it. This is true even for high-performance scintillators such as YAG:Ce, LuAG:Ce, LSO:Ce and their Pr-activated versions.<sup>61–64</sup> For example, YAG:Ce shows efficient photoluminescence ( $\sim 90\%$  of quantum yield<sup>61</sup>) and efficient



scintillation. Each of the emissions is resistant to thermal quenching up to about 600 K<sup>65</sup> and only above this temperature both the photoluminescence and scintillation get quenched rapidly.<sup>66,67</sup> It is a thermally induced coupling of the wave functions of the conduction band and the excited electronic level of the emitting center, which prevents the radiative relaxation of the excited electron. At elevated temperatures, the just mentioned thermal coupling disperses the electron cloud greatly within the conduction band precluding its bounding to the emitting level and making the luminescent transition unworkable. The effect of Ge content on the decay time was also analyzed for the blue-green luminescence from the <sup>3</sup>P<sub>0</sub> level and the red one from the <sup>1</sup>D<sub>2</sub> of Pr<sup>3+</sup>. Fig. S7a and b (ESI†) presents decay traces of the two emissions in all the Y<sub>2</sub>(Ge<sub>x</sub>Si<sub>1-x</sub>)O<sub>5</sub>:Pr phosphors under 250 nm (4f → 5d) excitation at 300 K. The kinetics of the emission from the <sup>1</sup>D<sub>2</sub> level is not affected by the Si:Ge ratio. However, the decay time of the <sup>3</sup>P<sub>0</sub> luminescence prolongs systematically from 2.5 to 8.6 μs between Y<sub>2</sub>SiO<sub>5</sub>:Pr and Y<sub>2</sub>GeO<sub>5</sub>:Pr, respectively (see Table S3, ESI†). This is understandable taking into account the lower-energy phonons appearing in the hosts with the incorporation of Ge, at the expense of the higher-energy vibrations of Si–O bonds. Consequently, with the increase of Ge content, the <sup>3</sup>P<sub>0</sub> level is continuously less-efficiently coupled with the next-lower-lying <sup>1</sup>D<sub>2</sub> level by means of multiphonon relaxation. The same does not apply to the kinetics of the <sup>1</sup>D<sub>2</sub> emission, as the next-lower-lying <sup>1</sup>G<sub>4</sub> level is separated from the emitting one by much higher energy (~0.9 eV/7000 cm<sup>-1</sup>), compared to the energy spanning <sup>3</sup>P<sub>0</sub> and <sup>1</sup>D<sub>2</sub> (~0.5 eV/4000 cm<sup>-1</sup>), see Fig. 1 and Fig. S4a (ESI†).

### 3.3. Thermometric analysis of Y<sub>2</sub>(Ge<sub>x</sub>Si<sub>1-x</sub>)O<sub>5</sub>:Pr

The potential of the phosphor systems as optical thermal sensors was initially assessed by analyzing the temperature dependence of their PL spectra in the 11–700 K range (see Fig. 4a–f). For this purpose, three luminescence bands related to transitions from the 5d<sub>1</sub>, <sup>3</sup>P<sub>0</sub>, and <sup>1</sup>D<sub>2</sub> levels were taken into account (see Fig. S4a, ESI†). It should be pointed out that the luminescence of Pr<sup>3+</sup> in the red part of the spectrum has a mixed origin – besides the emission from the <sup>1</sup>D<sub>2</sub> level, also transitions from the <sup>3</sup>P<sub>0</sub> one occur there. Distinguishing between them is thus crucial to maximizing the sensitivity of a given thermometer. Fortunately, differentiating these two emissions can be accomplished by employing time-resolved emission spectroscopy (TRES). The luminescence from the <sup>3</sup>P<sub>0</sub> level, being spin-allowed, decays much faster, than the emission from the <sup>1</sup>D<sub>2</sub> level. The decay time of the latter is typically up to two orders of magnitude longer. Fig. S8 (ESI†) presents results of the TRES measurements for the investigated compositions recorded at 11 K. It appears that, independently of the composition, in the 600–615 nm range only the long-decaying (~100–120 μs) luminescence from the <sup>1</sup>D<sub>2</sub> level is observed. At longer wavelengths, approximately up to 645 nm, a mixture of both the 4f → 4f transitions is observed. Finally, above 645 nm only luminescence from the <sup>3</sup>P<sub>0</sub> level occurs. Accordingly, Fig. S9 (ESI†) presents three luminescence bands selected for the thermometric analysis. Their integrated intensities are denoted A1, A2, and A3. The integration ranges

are listed in Table S4 (ESI†) and the values of the related band intensities as a function of temperature are presented in Fig. S10a–f (ESI†).

Consequently, the luminescence intensity ratio (LIR) was calculated according to the following equations:

$$\text{LIR}_1 = \frac{A1}{A2}, \text{LIR}_2 = \frac{A1}{A3}, \text{LIR}_3 = \frac{A2}{A3}, \quad (2)$$

where A1, A2, and A3 stand for the integrated areas of the three luminescence bands under consideration (see Fig. S8, ESI†). The evolution of the calculated LIR<sub>1</sub>, LIR<sub>2</sub>, and LIR<sub>3</sub> with temperature for all the investigated compositions is presented in Fig. S11a–j and S12a–f (ESI†). Errors in the determination of LIR were calculated according to eqn (S4) (ESI†). In most cases, the LIR<sub>1–3</sub> decreases continuously with increasing temperature. Yet, there are a few instances when LIR<sub>1–3</sub> does not follow this trend. This is inconvenient as it reduces the operating range of a specific thermometer.

Firstly, we shall focus on the temperature dependence of LIR<sub>1</sub> and LIR<sub>2</sub>—both contain the 5d → 4f luminescence intensity (A1). The temperature dependence of LIR<sub>1</sub> and LIR<sub>2</sub> could be fitted using the Mott-Seitz<sup>68,69</sup> equation for two independent non-radiative channels:<sup>28,29</sup>

$$\text{LIR}(T) \approx \frac{\text{LIR}_0}{1 + \sum_{i=1}^2 \alpha_i \exp\left(-\frac{\Delta E_i}{k_B T}\right)}, \quad (3)$$

where LIR<sub>0</sub> stands for the LIR parameter at 0 K (in practice, when no thermal quenching occurs), α represents the ratio between non-radiative (W<sub>0</sub> at T = 0 K) and radiative (W<sub>R</sub>) rates, and ΔE<sub>i</sub> represents the activation energy for the nonradiative relaxation channels. The fits of LIR<sub>1</sub> and LIR<sub>2</sub> are presented in Fig. S11a–j (ESI†), and the corresponding fitting parameters are included in Table S5 (ESI†). The obtained activation energies are consistent with those derived from the temperature dependence of the 5d → 4f luminescence decays, see Fig. 4 and eqn (1). This applies both to ΔE<sub>1</sub> and ΔE<sub>2</sub>, which is intriguing, even if the meaning of ΔE<sub>1</sub> remains unclear. As the Ge content in the host lattice increases, ΔE<sub>2</sub> lowers its value, while ΔE<sub>1</sub> remains almost unchanged (see Table S5, ESI†) – exactly as it was in the case of activation energies derived from the 5d → 4f luminescence decay times (see Fig. 5b).

Upon the spectroscopic analysis presented above, one has to realize that feeding the <sup>3</sup>P<sub>0</sub> level is somewhat complex, and with increasing temperature it is further complicated. In the case of <sup>1</sup>D<sub>2</sub>, it is even more tangled. This, in turn, makes the physics behind the temperature dependence of LIR<sub>3</sub> quite multifarious and problematic. Therefore, in the absence of a good physical model to rationalize the observed evolution of LIR<sub>3</sub> with temperature we used polynomial empirical functions. The results are presented in Fig. S12a–f (ESI†) and the fitting parameters are listed in Table S6 (ESI†). It appears that using intra-configurational transitions of Pr<sup>3+</sup> in Y<sub>2</sub>(Ge<sub>0.75</sub>Si<sub>0.25</sub>)O<sub>5</sub>:Pr allows measuring temperature over the whole accessible range – from 11 to 675 K. This is an important advantage of the solid-solution luminescence thermometers. Adjusting the Ge:Si



ratio one may find a phosphor offering what a stoichiometric silicate or germanate cannot.

The repeatability of the temperature readouts for each analyzed material, as well as the stability of the temperature-dependent intensity ratios ( $LIR_1$ ,  $LIR_2$ , and  $LIR_3$ ) were examined during 10 consecutive cycles of heating-cooling (Fig. S13a–f, ESI†). The calculated repeatability (eqn S5, ESI†) does not fall below 99% which proves the excellent thermal stability of the luminescence generated by the investigated phosphors.

In order to compare the performance of the temperature sensing based on the three luminescence intensity ratios ( $LIR_1$ ,  $LIR_2$ ,  $LIR_3$ ) quantitatively, their relative sensitivities,  $S_r$  (%  $K^{-1}$ ), were determined using eqn (4):<sup>19</sup>

$$S_r = \frac{1}{LIR} \left| \frac{\partial LIR}{\partial T} \right|. \quad (4)$$

The errors of the corresponding  $S_r$  values were calculated using eqn (S6) (ESI†). Fig. 6 presents the calculated relative thermal

sensitivities for  $LIR_1$  (Fig. 6a),  $LIR_2$  (Fig. 6b), and  $LIR_3$  (Fig. 6c). In the case of  $S_r(LIR_1)$  and  $S_r(LIR_2)$ , the highest relative sensitivity  $S_r = 3.60\% K^{-1}$  at 353 K was obtained for the Ge-free  $Y_2SiO_5:Pr$  material. It is notable that in each of the analyzed compositions the maximal relative sensitivity ( $S_m$ ) exceeds  $2\% K^{-1}$ , which makes all of them excellent luminescence thermometers. As the Ge content increases, the  $S_m$  shifts towards lower temperature values. It mirrors the decreasing temperature of the  $5d \rightarrow 4f$  luminescence quenching, as presented in Fig. 4, 5, and Fig. S10 (ESI†). Hence, through bandgap engineering, it is possible to effectively control the temperature range of the maximum sensitivity (best performance) of the luminescent thermometers. Fig. 6c presents the relative sensitivity based on the  $LIR_3$  (eqn (4)).

It is striking that the  $S_r(LIR_3)$  values are noticeably lower than those based on  $LIR_1$  or  $LIR_2$  (dependent very much on the  $5d \rightarrow 4f$  luminescence). They vary from nearly 0 to  $0.74\% K^{-1}$ . The highest  $S_r(LIR_3)$  was obtained for  $Y_2GeO_5$  at 600 K. Thus, also when the  $4f \rightarrow 4f$  emissions are exploited, the performance

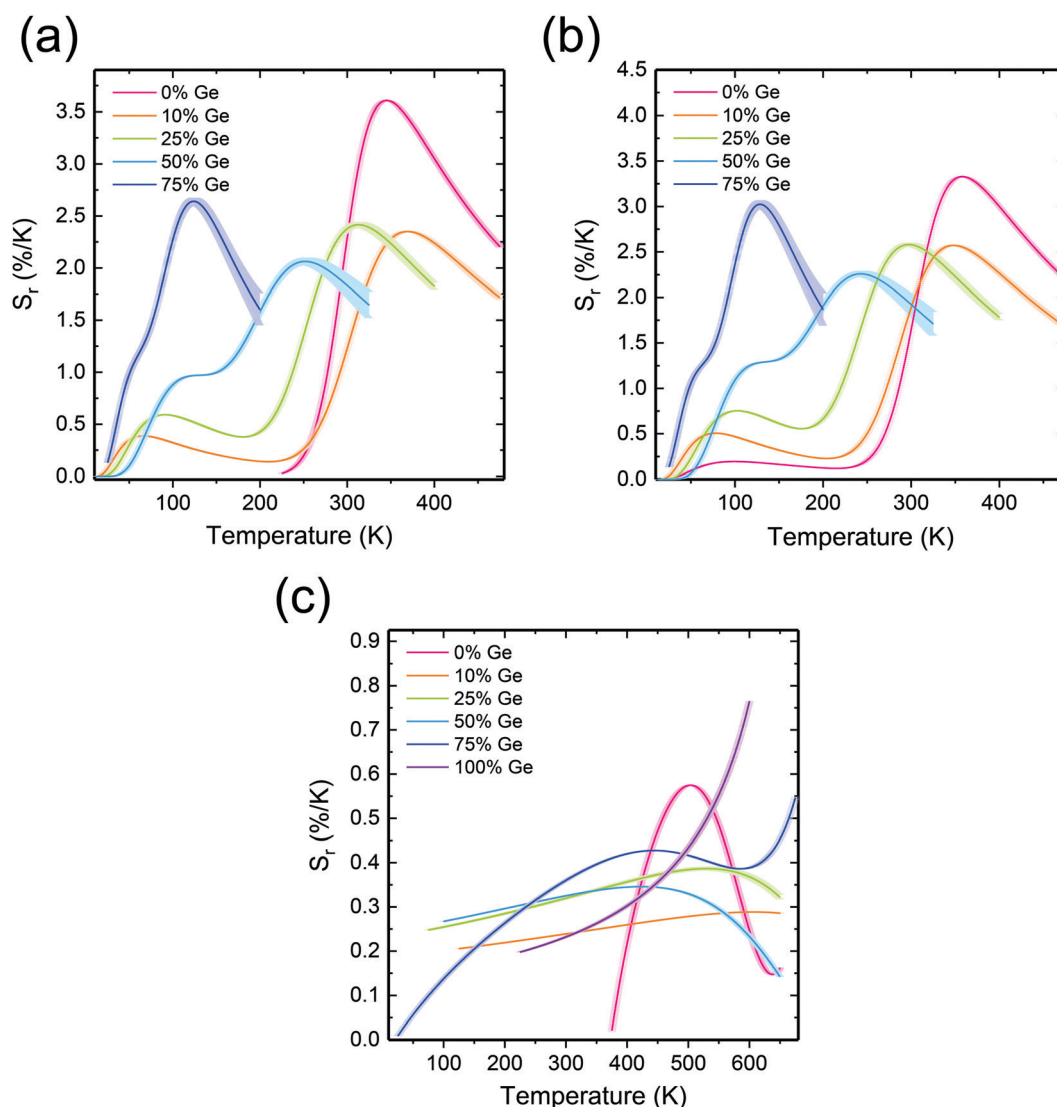


Fig. 6 Temperature dependence of the relative thermal sensitivity (eqn (4)) based on (a)  $LIR_1$ , (b)  $LIR_2$ , and (c)  $LIR_3$ .





of the luminescence thermometers may be tailored by means of non-stoichiometry of the host lattice.

Corresponding temperature resolution,  $\delta T$ , of the investigated thermometers, was calculated using eqn S7 (ESI<sup>†</sup>), and the results are presented in Fig. S14a–c (ESI<sup>†</sup>). For  $LIR_1$  and  $LIR_2$  the temperature uncertainty varies from 0.01 K to 4 K. At the lowest temperature values (<30 K), the uncertainty exceeds 4 K. This reflects the low  $S_r$  values in this region. Then, when the temperature increases,  $\delta T$  decreases accordingly to again increase at the high-temperature part of the operating range. In the case of the samples containing 50% and 75% of Ge, the thermometer deficiency is that  $\delta T$  drastically increases above 250 K and 150 K, respectively. This is understandable, as the  $5d \rightarrow 4f$  luminescence is severely quenched in these compositions (see Fig. 4 and 5). Such an effect enlarges the  $\delta LIR/LIR$  values accordingly for these phosphors, which directly leads to the larger  $\delta T$  values. Since the uncertainty is a function (somewhat complex) of the signal to noise ratios, whenever one of them is low this parameter is expected to increase. This anticipation is perfectly mirrored by the  $T$ -dependences of the uncertainties presented in Fig. S14 (ESI<sup>†</sup>). They indeed increase at the limits of the operating range when one of the emissions used for calculations shows indeed low intensity.

Among the investigated compositions, the very good candidate for temperature sensing is  $Y_2Ge_{0.10}Si_{0.90}O_5:Pr$ . It offers the best combination of high accuracy, high sensitivity, and a wide operating  $T$ -range (11–500 K). Temperature uncertainty based on the  $4f \rightarrow 4f$  (Fig. S14c, ESI<sup>†</sup>) varies from 0.01 to 1 K, which is excellent accuracy, especially at high temperatures. In the Si-free  $Y_2GeO_5:Pr$  phosphor,  $\delta T$  is as low as 0.1 K, within its whole operating  $T$ -range, *i.e.*, 200–600 K (Fig. S14c, ESI<sup>†</sup>), which is an impressive achievement. This results from the fact that in this phosphor, the excitation energy delivered to the  $5d$  level is used to generate only the  $4f \rightarrow 4f$  luminescence, resulting in high intensity of the emission features and consequently high signal-to-noise ratio.

Due to significant temperature dependence, it was tempting to exploit the decay time of the  $5d \rightarrow 4f$  luminescence for temperature measuring as well (see Fig. 5). To analyze the performance quantitatively, the relative thermal sensitivities,  $S_r$ , were calculated (using eqn (2), and replacing  $LIR$  by  $\tau$ ) for the phosphors showing the  $5d \rightarrow 4f$  luminescence. Fig. 7 presents how the  $S_r$  changes with temperature for each of the examined compositions when the decay time of the intra-configurational transition is used. Importantly, the range of the temperature reading, as well as the temperature at which the  $S_m$  is achieved may be effectively tuned by varying the Si:Ge ratio. The general trend is that with the increasing Ge content the  $S_m$  continuously shifts to lower temperature values. This echoes the decreasing temperature of the  $5d \rightarrow 4f$  luminescence quenching (see Fig. 4 and 5a). In the Ge-free  $Y_2SiO_5:Pr$  sample,  $S_m$  reaches a respectable value of  $2.67\% K^{-1}$  at 417 K.

As the Ge content increases, both the operating  $T$ -range and the temperature of  $S_m$  continuously shifts towards lower temperature values. This enables effective tuning of the thermometer

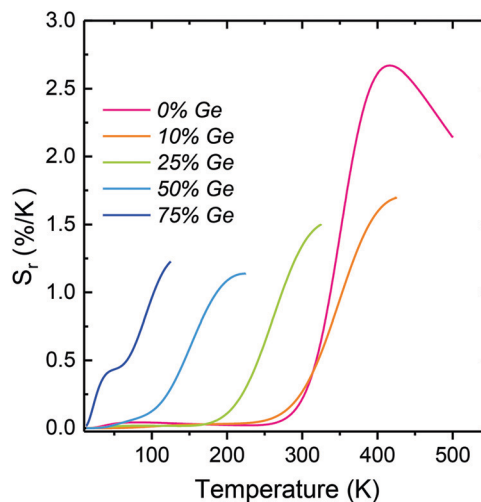


Fig. 7 Relative thermal sensitivity ( $S_r$ ) based on the  $5d \rightarrow 4f$  decay traces of the  $Y_2(Ge_xSi_{1-x})O_5:Pr$  materials.

performance when the  $5d \rightarrow 4f$  luminescence decay time is exploited. Furthermore, the temperature resolution ( $\delta T$ ) of the measurements was calculated using eqn (S11) (ESI<sup>†</sup>) and the results are presented in Fig. S15 (ESI<sup>†</sup>). The resulting uncertainties of the temperature readouts are very low and vary in the range of 0.1–0.001 K. Thus, reading the temperature by means of the  $5d \rightarrow 4f$  luminescence decay time allows achieving exceptionally high accuracy of the readout. The important source of the impressive accuracies is the fact that the decay traces are single-exponential and this allows for a low standard deviation of the decay time values derived from their fits.

### 3.4. High-pressure response

The response of the following three samples,  $Y_2(Ge_xSi_{1-x})O_5:Pr^{3+}$ , where  $x = 0, 0.10$ , and  $0.25$  of Ge, to external high pressure was investigated by their compression in a diamond anvil cell (DAC). The selected samples show a relatively intense  $5d \rightarrow 4f$  luminescence. Compression of the materials was performed within the hydrostatic pressure range, *i.e.*, up to about 10 GPa. The excitation and emission spectra were recorded for  $\lambda_{em} = 320$  nm and  $\lambda_{ex} = 248$  nm, respectively. The results are presented in Fig. 8 and 9. We focused on the inter-configurational  $5d \rightarrow 4f$  transition of  $Pr^{3+}$ , which is much more sensitive to external stimuli (*e.g.*, pressure or temperature), compared to the intra-configurational  $4f \rightarrow 4f$  transitions.<sup>70–73</sup> Fig. 8a–c shows the pressure dependence of the (normalized) emission spectra for the investigated phosphors.

The  $5d \rightarrow 4f$  emission feature around 300 nm shows the pressure-induced spectral shift to longer wavelengths (Fig. 8d–f), as well as the non-monotonic variations in the relative intensities of the  $5d \rightarrow 4f$  bands with respect to the  $4f \rightarrow 4f$  ones. The latter effect is plausibly caused by a different pressure-induced quenching effect for the intra- and inter-configurational transitions. As expected, similarly to emissions, the excitation spectra presented in Fig. 9a–c also showed a spectral shift with the increasing pressure values. The spectral positions of the peak



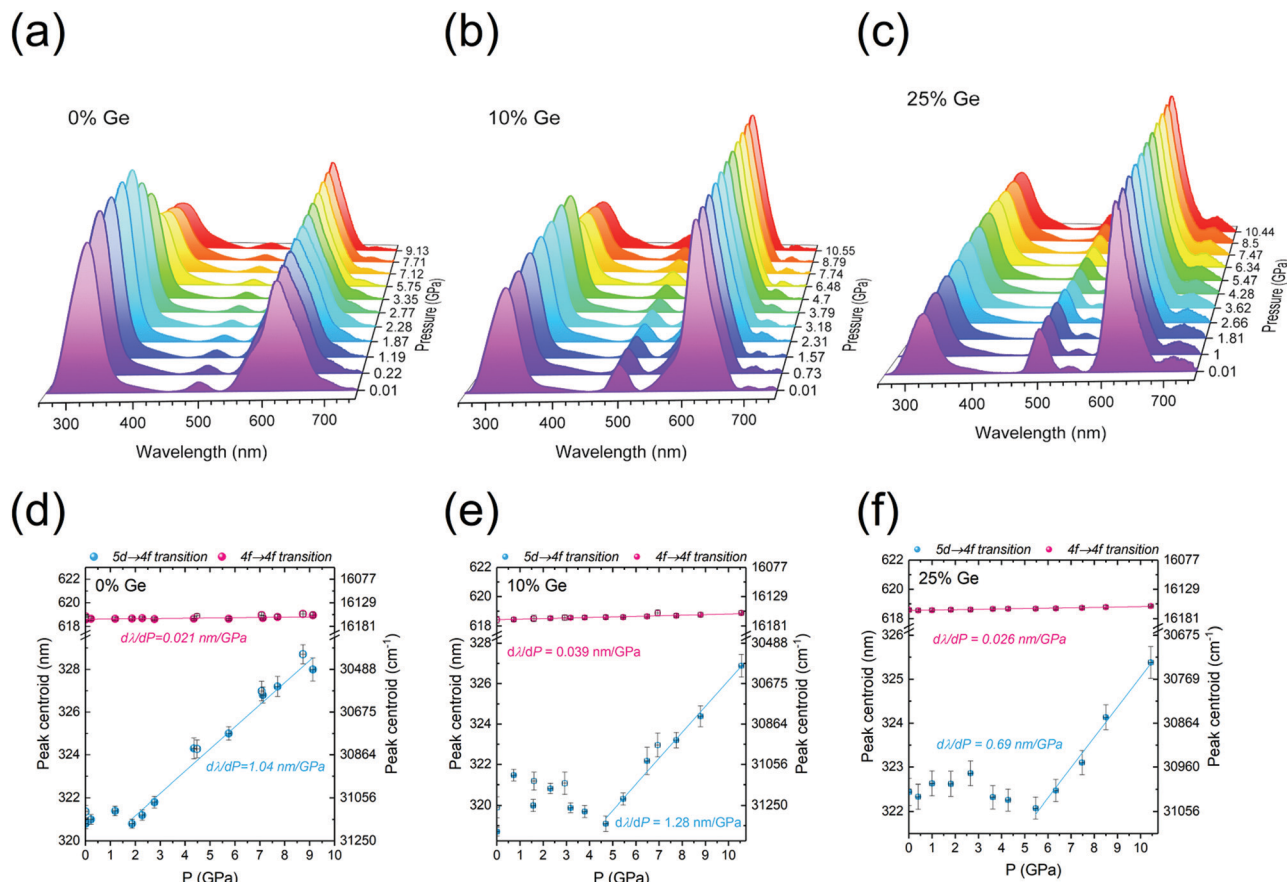


Fig. 8 PL emission spectra of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}^{3+}$ , where  $x =$  (a) 0, (b) 0.10, and (c) 0.25 ( $\lambda_{\text{ex}} = 248$  nm), measured as a function of pressure, in the range of 0–10 GPa. The determined spectral positions of the  $\text{Pr}^{3+}$  4f  $\rightarrow$  4f (red) and 5d  $\rightarrow$  4f (blue) emission bands, as a function of pressure for 0, 0.10, and 0.25 of Ge are presented in (d)–(f), respectively.

centroids are presented in Fig. 8d–f and 9d–f, for the emission and excitation spectra, respectively.

The data reveal very significant linear shifts of the  $\text{Pr}^{3+}$  f  $\rightarrow$  d transitions. For the emission spectra, the  $d\lambda_{\text{PL}}/dP = 1.04$ , 1.28 and 0.69 nm  $\text{GPa}^{-1}$ , and for excitation ones the  $d\lambda_{\text{PLE}}/dP = 0.49$ , 0.43 and 0.56 nm  $\text{GPa}^{-1}$ , for the samples containing 0, 10 and 25% of Ge, respectively. These values are by more than an order of magnitude higher than in the case of the 4f  $\rightarrow$  4f of  $\text{Pr}^{3+}$  ( $^1\text{D}_2 \rightarrow ^3\text{H}_4/^3\text{P}_0 \rightarrow ^3\text{H}_6$ ) emission transitions, see Table 1. Such difference between the intra- and inter-configurational transitions is typical for lanthanide ions.<sup>70,71,74</sup> Consequently, the 4f  $\rightarrow$  4f transitions offer a much lower sensitivity in pressure measuring than the intra-configurational ones. It is noteworthy that in the case of the pressure-dependent emission spectra, the position of the 5d  $\rightarrow$  4f band peak centroid is relatively constant at the low-pressure range. It does not shift at the initial stage of the compression (up to  $\sim 2$  GPa for the Ge-free sample, and up to  $\sim 5$  GPa for the Ge-doped samples), as can be observed in Fig. 8d–f. It should be emphasized that there are several pressure-induced effects, which may lead to a shift of the bands in excitation and/or emission spectra. These are: (i) enhanced splitting of the multiplets, caused by the increased crystal-field strength due to the shortening of the

interionic distances upon compression; (ii) a more pronounced nephelauxetic effect, *i.e.*, decreased spin–orbit interactions and ionic character of bonding (bonds become more covalent); (iii) larger Stokes shift, due to the enhanced electron–phonon coupling, associated with increased phonon energies with pressure.<sup>70–74</sup> Raman spectroscopy confirmed pressure-induced structural distortion of the structure in isostructural  $\text{Lu}_{1.8}\text{Y}_{0.2}\text{SiO}_5$  single crystals.<sup>75</sup> The coincidence of the mentioned effects may account for the initial fluctuations/deviations in the spectral position of the  $\text{Pr}^{3+}$  5d  $\rightarrow$  4f emissions.

One of the most important properties of pressure sensing is the reversible character of the observed spectral shifts. It is perfectly proved by the decompression data (empty symbols in Fig. 8d–f and 9d–f), which converge with the results of the compression runs. In Table 1, the performance of the investigated materials, *i.e.*, their shift rates for the 5d  $\rightarrow$  4f emission and 4f  $\rightarrow$  5d excitation bands were compared with other highly-sensitive luminescent manometers reported up to now. It is noteworthy that the determined shift rates for the presently developed  $\text{Pr}^{3+}$ -doped  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  luminescent manometers are much larger, compared to the commonly used ruby ( $\text{Al}_2\text{O}_3:\text{Cr}^{3+}$ ;  $d\lambda/dP \sim 0.36$  nm  $\text{GPa}^{-1}$ ) and  $\text{Sm}^{2+}$ -based ( $\text{SrB}_4\text{O}_7:\text{Sm}^{2+}$ ;  $d\lambda/dP \sim 0.25$  nm  $\text{GPa}^{-1}$ ) pressure sensors.<sup>76,77</sup> The sample containing 10% of Ge is the



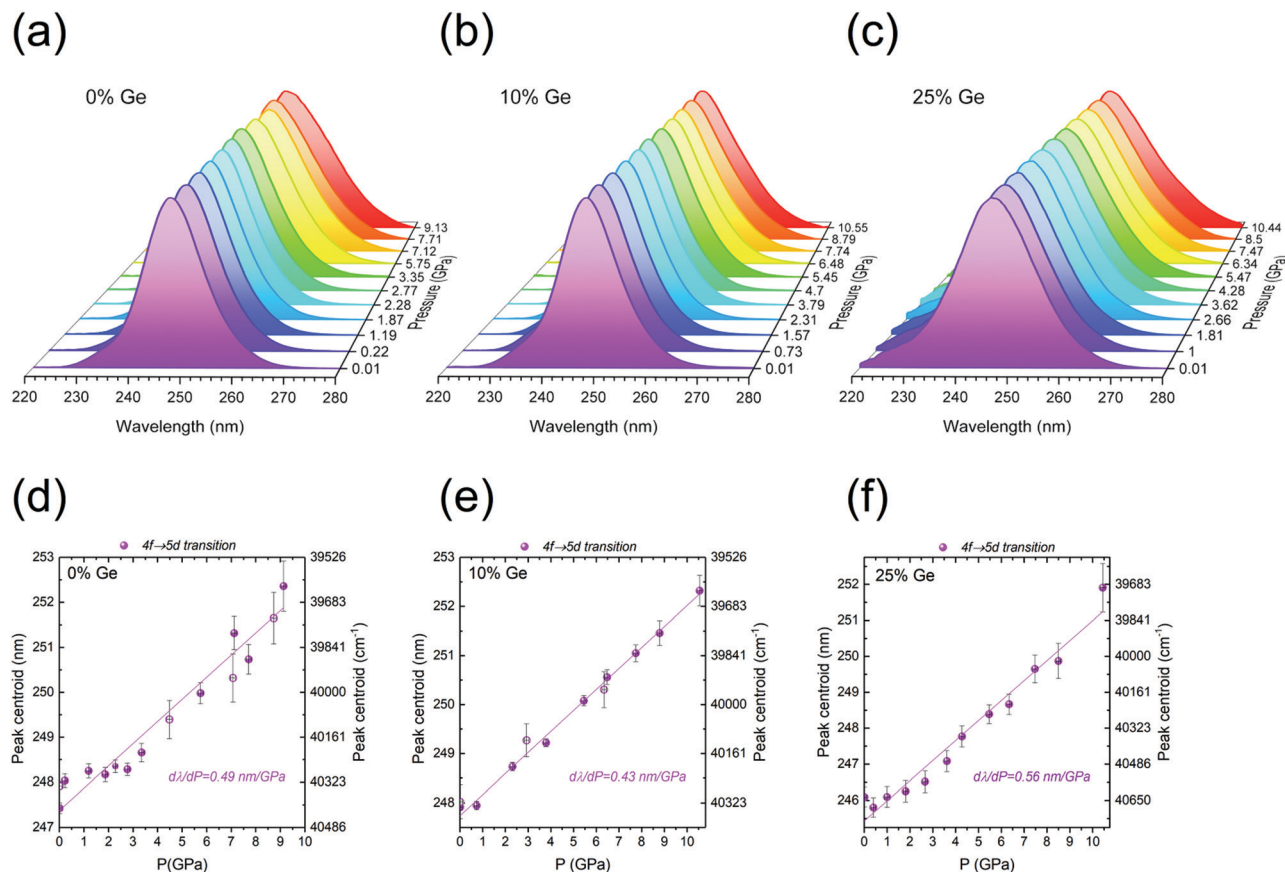


Fig. 9 Normalized PLE spectra of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  samples with 320 nm luminescence as a function of pressure, where  $x =$  (a) 0, (b) 0.10, and (c) 0.25 of Ge. Spectral positions of the  $4f \rightarrow 5d$  excitation band for the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:\text{Pr}$  samples, where  $x =$  (d) 0, (e) 0.10, and (f) 0.25.

Table 1 Performance comparison of the most sensitive, shift-based sensors of high pressure

Sensor	Dopant ion	Line shift ( $\text{nm GPa}^{-1}$ )	Transition	$\lambda$ (nm)	Ref.
$\text{Y}_2\text{SiO}_5$	$\text{Pr}^{3+}$	1.04	$5d \rightarrow 4f$	320	This work
		0.49	$4f \rightarrow 5d$	248	
		0.021	$4f \rightarrow 4f$	618	
$\text{Y}_2\text{Ge}_{0.10}\text{Si}_{0.90}\text{O}_5$	$\text{Pr}^{3+}$	1.28	$5d \rightarrow 4f$	320	
		0.43	$4f \rightarrow 5d$	248	
		0.039	$4f \rightarrow 4f$	618	
$\text{Y}_2\text{Ge}_{0.25}\text{Si}_{0.75}\text{O}_5$	$\text{Pr}^{3+}$	0.69	$5d \rightarrow 4f$	320	
		0.56	$4f \rightarrow 5d$	248	
		0.026	$4f \rightarrow 4f$	618	
$\text{Al}_2\text{O}_3$ (ruby)	$\text{Cr}^{3+}$	0.365	${}^2\text{E} \rightarrow {}^4\text{A}_2$	694	76
$\text{YAlO}_3$	$\text{Cr}^{3+}$	0.70	${}^2\text{E} \rightarrow {}^4\text{A}_2$	723	78
$\text{CeN-PVDF}$	$\text{Ce}^{3+}$	0.28	$5d \rightarrow 4f$	327	79
$\text{Y}_6\text{Ba}_4(\text{SiO}_4)_6\text{F}_2$	$\text{Ce}^{3+}$	0.63	$5d \rightarrow 4f$	466	73
$\text{BaLi}_2\text{Al}_2\text{Si}_2\text{N}_6$	$\text{Eu}^{2+}$	1.58	$5d \rightarrow 4f$	532	72
$\text{EuPO}_4$	$\text{Eu}^{3+}$	$\sim 0.27$	${}^5\text{D}_0 \rightarrow {}^7\text{F}_0$	580	80
$\text{NaBiF}_4$	$\text{Er}^{3+}$	$-0.80$	${}^4\text{I}_{13/2} \rightarrow {}^4\text{I}_{15/2}$ (stark)	1503	81
$\text{YPO}_4$	$\text{Er}^{3+}$	0.539	${}^4\text{I}_{13/2} \rightarrow {}^4\text{I}_{15/2}$ (stark)	1589	82
$\text{Gd}_3\text{Sc}_2\text{Ga}_3\text{O}_{12}$	$\text{Nd}^{3+}$	$\sim 0.632$	${}^4\text{F}_{3/2} \rightarrow {}^4\text{I}_{9/2}$ (stark)	935	83
$\text{Y}_3\text{Al}_5\text{O}_{12}$	$\text{Sm}^{3+}$	0.30	${}^4\text{G}_{5/2} \rightarrow {}^6\text{H}_{7/2}$ (stark)	618	84
$\text{SrFCl}$	$\text{Sm}^{2+}$	1.11	${}^5\text{D}_0 \rightarrow {}^7\text{F}_0$	690	85
$\text{SrB}_4\text{O}_7$	$\text{Sm}^{2+}$	0.255	${}^5\text{D}_0 \rightarrow {}^7\text{F}_0$	685	77
$\text{SrB}_2\text{O}_4$	$\text{Sm}^{2+}$	0.244	${}^5\text{D}_0 \rightarrow {}^7\text{F}_0$	685	86

second most sensitive luminescent pressure sensor based on the emission band shift ( $d\lambda/dP \sim 1.28 \text{ nm GPa}^{-1}$ ) ever reported. The

leading composition is the recently published  $\text{BaLi}_2\text{Al}_2\text{Si}_2\text{N}_6:\text{Eu}^{2+}$  sensor excitable in a visible spectral range ( $d\lambda/dP \sim 1.58 \text{ nm GPa}^{-1}$ ).<sup>72</sup>



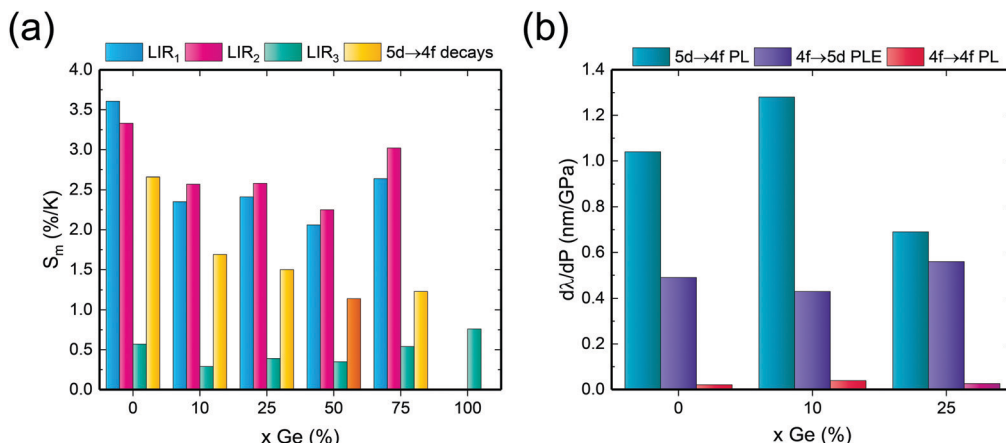


Fig. 10 Histogram displaying the (a) maximal thermal relative sensitivity, and (b) pressure absolute sensitivity of the investigated phosphors.

## 4. Conclusions and summary

This paper explored the effect of bandgap engineering on the spectroscopy of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:0.05\%\text{Pr}$  powder phosphors, and – more importantly – on their performance as luminescence thermometers and manometers. These are among the most paramount emerging technological applications of phosphors nowadays. It was demonstrated that – when the Ge content increases (at the expense of Si) – the energetic position of the bottom of the host conduction band lowers, and some other effects take place simultaneously. Very important among them is the lowering of the energy of available phonons, from about 850–1150  $\text{cm}^{-1}$  in  $\text{Y}_2\text{SiO}_5$  to  $\sim 770 \text{ cm}^{-1}$  in  $\text{Y}_2\text{GeO}_5$ . This, in turn, affects the rates of radiative/non-radiative relaxation processes experienced by the electrons raised to the  $\text{Pr}^{3+}$  5d excited level by the  $\sim 250 \text{ nm}$  excitation radiation.

Despite the interplay of different effects, when the Ge:Si ratio changes, fairly systematic variations in the luminescence properties are observed when Ge replaces Si in the host lattice. Accordingly, monotonic changes of thermometric parameters of the phosphors occur then. Consequently, the properties and quality of the  $\text{Y}_2(\text{Ge}_x, \text{Si}_{1-x})\text{O}_5:\%\text{Pr}$  luminescent thermometers may be tuned and managed by changing the Ge content ( $x$  value).

In the Si-rich materials, the cross-over mechanism of the 5d → 4f luminescence quenching dominates, while in the Ge-rich phosphors the thermally-induced photoionization prevails. This difference has further consequences, as in the latter the ionized electrons have little chance to produce any luminescence. They dissipate their excessive energy mostly non-radiatively. Yet, in the cross-over mechanism of quenching of the 5d → 4f emission, the excited electron is conveyed directly to the lower-lying  $^3\text{P}_j$  (and possibly further to  $^1\text{D}_2$  by multiphonon relaxation) levels. It is clear that all these effects are reflected in thermometric properties of the investigated phosphors. In consequence, it may be taken as a universal “rule of thumb”, that the properties of luminescent thermometers may be deliberately designed by means of non-stoichiometry of the host lattices.

We confirmed that luminescence of  $\text{Pr}^{3+}$  is attractive for luminescence thermometry using all its three emissions, from

5d,  $^3\text{P}_0$  and,  $^1\text{D}_2$  levels. Since each of them shows different dependences on temperature, accurate temperature measurements over the  $T$ -range from 11 to 600–700 K can be executed. Furthermore, the temperature range of their highest sensitivity may be intentionally tuned making use of the bandgap engineering. Since both the  $\text{Pr}^{3+}$  luminescence intensity ratio and the decay time of its 5d → 4f emission are strongly temperature-dependent, these phosphors may easily serve as dual-mode sensitive thermometers, which makes them even more versatile. This is adequately shown in Fig. 10a, which compares the highest relative thermal sensitivities achievable using the four different thermometric parameters we tested for the series of  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:0.05\%\text{Pr}$  phosphors. Those of them which use the properties of the 5d → 4f luminescence beat the one based on the 4f → 4f emissions.

The manageable thermometric capabilities of the  $\text{Y}_2(\text{Ge}_x\text{Si}_{1-x})\text{O}_5:0.05\%\text{Pr}$  powders are complemented by a commendable functioning of these phosphors in manometry. At least up to about 10 GPa (and plausibly even higher) the sensitivity of the  $\text{Y}_2(\text{Ge}_{0.10}\text{Si}_{0.90})\text{O}_5:0.05\%\text{Pr}$  phosphor is the second best reported up to now (1.28 nm  $\text{GPa}^{-1}$ ), when the pressure-induced shift of the emission band is employed. Also, in this case, a very good result was achieved exploiting the 5d → 4f luminescence of  $\text{Pr}^{3+}$ , which is highly-sensitive to the changes in the ion coordination sphere, due to the good exposure of the excited 5d orbitals to their external environment. The comparison of the sensitivity in pressure measurements using the spectral shift of the 5d<sub>1</sub> → 4f excitation and emission transitions and the 4f → 4f luminescence band is given in Fig. 10b. The latter effect is much less significant than any of the two transitions involving the 5d orbitals. Indeed, the 5d → 4f electronic transitions of the  $\text{Pr}^{3+}$  ions may be very useful for designing sensitive luminescence thermometers and manometers.

## Author contributions

MS: conceptualization, data curation, formal analysis, investigation, methodology, project administration, visualization, writing – original draft. MR: funding acquisition, formal





analysis, methodology, writing – original draft (manometry). PW: investigation, methodology. LDC: funding acquisition, validation, writing – review & editing. EZ: funding acquisition, conceptualization, supervision, writing – review & editing. SL: writing – review & editing, validation.

## Conflicts of interest

The authors declare no conflict of interest.

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